

General Description:

Silicon epitaxial chip of p-n-p medium power transistor (I_c max=3A) used for general-purpose amplifier and switching application.

Complementary pair TIP31C

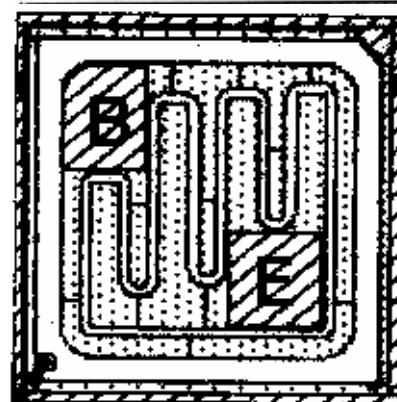
Wafer Diameter -- 100 mm
 Wafer thickness -- $270 \pm 20 \mu\text{m}$;
 Die size -- 1.7 x 1.7 mm ;

Metallization:

Top -- Al $4.5 \pm 0.5 \mu\text{m}$
 Bottom -- Ti-Ni-Ag
 $\quad \quad \quad \text{Ti} = 0.1 \pm 0.02 \mu\text{m}$
 $\quad \quad \quad \text{Ni} = 0.5 \pm 0.1 \mu\text{m}$
 $\quad \quad \quad \text{Ag} = 0.6 \pm 0.1 \mu\text{m}$

Bondpad size:

1. Base 0.4 x 0.3 mm
2. Emitter 0.312 x 0.312 mm



Recommended ultrasonic bonding wire Al
 Emitter - 2 wire dia $80 \mu\text{m}$
 Base - 1 wire dia $80 \mu\text{m}$

ELECTRICAL CHARACTERISTICS CHIPS ON WAFER (Ta=25°C)

Parameter	Symbol	Unit	Measurement Mode	Min	Max
Collector cutoff Current	I_{CEO}	mA	$V_{CE}=45\text{V}; I_B=0$		0.3
Collector cutoff Current	I_{CES}	mA	$V_{CE}=60\text{V}; U_{BE}=0$		0.2
Emitter cutoff Current	I_{EBO}	mA	$V_{EB}=5,0 \text{ V}; I_C=0$		1.0
Collector – Emitter Sustaining	V_{CEO} (sus)	V	$I_C=30 \text{ mA}, I_B=0$	60	
DC Current Gain(1) **	h_{FE}		$V_{CE}=4\text{V}; I_C=1\text{A}$	100	
Small-Signal Current Gain **	h_{fe}		$V_{CE}=10\text{V}; I_C=0,5 \text{ A}$ $f=1\text{kHz}$	20	
Collector-Emitter Saturation Voltage(1)	$V_{CE(sat)}$	V	$I_C=1\text{A}; I_B=35\text{mA}$		0.5
Base- Emitter On Voltage(1) **	$V_{BE(on)}$	V	$V_{CE}=4 \text{ V}; I_C=3 \text{ A}$		1.8

 1.Pulse Tests: Pulse Width $\leq 300 \mu\text{s}$, Duty Cycle $\leq 2\%$

 2.** In a circuit with common base $U_{CB} = U_{CE}-1\text{V}$; $I_E = I_C$